

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Vignia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/596,837	06/19/2000	Vladimir Vaganov	SS-714-01	2878
75	590 07/30/2003			
Law Offices of Thomas E Schatzel A Professional Corporation Suite 240			EXAMINER	
			GOUDREAU, GEORGE A	
16400 Lark Avenue Los Gatos, CA 95032-2547			ART UNIT	PAPER NUMBER
			1763 ·	6
			DATE MAILED: 07/30/2003	• -

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No. Applicant(s) O9-596,837 Examiner Group Art Unit				
<u> </u>	George Goudream 1763				
-The MAILING DATE of this communication appears on the cover sheet beneath the correspondence address-					
Period for Reply	· Q				
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO OF THIS COMMUNICATION.	EXPIRE MONTH(S) FROM THE MAILING DATE				
from the mailing date of this communication. If the period for reply specified above is less than thirty (30) days, a replace of the period for reply is specified above, such period shall, by default, Failure to reply within the set or extended period for reply will, by statuent and the process of the office later than three months after the mailing term adjustment. See 37 CFR 1.704(b).	te, cause the application to become ABANDONED (35 U.S.C. § 133). ng date of this communication, even if timely, may reduce any earned patent				
Responsive to communication(s) filed on 5-03	(ie, paper #5)-				
☐ Since this application is in condition for allowance except f accordance with the practice under Ex parte Quayle, 1935.					
Disposition of Claims					
(Claim(s) -1/5	is/are pending in the application.				
Of the above claim(s)	is/are withdrawn from consideration.				
$\sqrt{\text{Claim(s)}}$ $\frac{56-65}{\sqrt{20-12}}$ $\frac{12-19}{\sqrt{20-12}}$ $\frac{12-19}{$	is/are allowed. 3, 46-54, 111 is/are rejected. 15, 5566-71 is/are objected to.				
□ Claim(s)	are subject to restriction or election				
Application Papers	requirement				
☐ The proposed drawing correction, filed on is ☐ approved ☐ disapproved.					
☐ The drawing(s) filed on is/are objected to by the Examiner					
☐ The specification is objected to by the Examiner.					
☐ The oath or declaration is objected to by the Examiner.					
Priority under 35 U.S.C. § 119 (a)-(d)	•				
☐ Acknowledgement is made of a claim for foreign priority un	der 35 U.S.C. § 119 (a)-(d).				
☐ All ☐ Some* ☐ None of the:					
☐ Certified copies of the priority documents have been rec					
☐ Certified copies of the priority documents have been received in Application No					
☐ Copies of the certified copies of the priority documents					
in this national stage application from the International I *Certified copies not received:					
Attachment(s)					
☐ Information Disclosure Statement(s), PTO-1449, Paper No(s) ☐ Interview Summary, PTO-413					
□ Notice of Reference(s) Cited, PTO-892	☐ Notice of Informal Patent Application, PTO-152				
☐ Notice of Draftsperson's Patent Drawing Review, PTO-948	□ Other				
Office Action Summary					

Application/Control Number: 09/596,837

Art Unit: 1763

- 15. This action will not be made final due to the new grounds of rejection.
- 16. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 17. Claims 1-7, and 9-11 are rejected under 35 U.S.C. 102(b) as being anticipated by Laou et. al. (5,857,885).

Laou et. al. disclose a two step etching process for etching a trench into a CZ-Si wafer which is comprised of the following steps:

- -A patterned SiO2 or Si3N4 hard mask (8) is formed onto the surface of the <100> plane of a CZ-Si wafer.;
- -The Si wafer is isotropically wet etched in a (HNO3-HF-acetic-H2O) solution.;
- -A Cr or Mo layer is deposited onto the surface of the wafer.; and
- -The Si wafer is anisotropically wet etched along the <111> plane using a (KOH-H2O) solution.

This is discussed specifically in columns 3-4; and discussed in general in columns 1-6.

This is shown in figures 1-14.

Application/Control Number: 09/596,837

Art Unit: 1763

- 18. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 19. Claims 8, and 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over the reference as applied in paragraph 17 above.
 - The reference as applied in paragraph 17 above fail to disclose the following aspects of applicant's claimed invention:
 - -the specific usage of ultrasonic or megasonic vibration of the wet etchant during the wet etching steps

It would have been obvious to one skilled in the art to employ ultrasonic or megasonic means to the wet etchant during any of the wet etching steps taught above based upon the following. The usage of ultrasonic or megasonic means to enhance a wet etching process is conventional or at least well known in the wet etching arts. (The examiner takes official notice in this regard.) Further, the usage of such means to enhance a wet etching process would desirably provide a means for accelerating the wet etching process which would desirably increase the possible through put of such a process.

Application/Control Number: 09/596,837

Art Unit: 1763

- 20. Claims 7-8, 11-12, 20-22, 31-34, 42-43, 46-54, and 111 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.
 - -In claims 7-8, 12, 20-21, 31, 42-43, 46, 49, and 53, "said anisotropic" lacks proper antecedent basis.; and
 - -In claim 111, "parylen" should read "parylene".
- 21. Claims 13-19, 23-30, 35-41, 44-45, 55, and 66-71 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 22. Claims 56-65, 72-110, and 112-115 are allowed.
- Claims 20-22, 31-34, 42-43, and 46-54 would be allowable if rewritten to overcome the rejection(s) under 35 U.S.C. 112, 2nd paragraph, set forth in this Office action and to include all of the limitations of the base claim and any intervening claims.
- 24. Claim 111 would be allowable if rewritten or amended to overcome the rejection(s) under 35 U.S.C. 112, 2nd paragraph, set forth in this Office action.
- 25. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner George A. Goudreau whose telephone number is (703) -308-1915. The examiner can normally be reached on Monday through Friday from 9:30 to 6:00.

Application/Control Number: 09/596,837 Page 5

Art Unit: 1763

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Examiner Gregory Mills, can be reached on (703) -308-1633. The appropriate fax phone number for the organization where this application or proceeding is assigned is (703) -306-3186.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) -308-0661.

George A. Goudreau/gag

Primary Examiner

AU 1763